

# **Indium8.9HF** Halogen-Free Solder Paste



# **Technology Drivers**

- High reliability
  - Server, telecommunication, automotive
- Miniaturization
  - Multi-Functionality
    - PDA, Cell Phone, IPOD
  - Board Real Estate is a Premium
  - Components Continue to "Shrink"
- High Density on Large Boards
  - 0201 on Servers
  - CSP on Motherboards





### Materials & Applications Development Primary Goals

- Full Product Characterization
  - Prior to Release
- Shared Projects & Test Vehicles
- Joint Projects with Industry Leaders
- Research & Development
  - Assist in Product Characterization
  - New Product Design Challenges
- Quality Assurance
  - Testing Methods & Criteria
- Verify Indium Materials exceed Industry & Customer Requirements!







### New Solder Paste Technology Performance Requirements

- Printability
  - Area Ratio's below 0.66
  - High Slump Resistance
- Voiding
  - Micro Via-in-Pad
  - BGA
  - QFN (leadless)
- Wetting
  - Pb-Free Finishes
  - R-Nets & QFN's
  - Long Air Profiles
- Residue
  - Halogen-Free
  - Color
  - Probe-ability





#### Halogen-Free vs. Halide-Free

#### Halogen-Free

- It does not contain Cl, Br, F, I, At (although most just looking at Cl and Br)
- Concern is Environmental
  - Uncontrolled incineration
  - Dioxin formation
- No legislation around halogen elimination
- Flame Retardants
- Issues:
  - Do the halogen free PCB's impact end product reliability?

#### Halide-Free

- Should be halide ion free as it is defined in electronics as not containing ionic halides.
- Concern is Reliability
  - Corrosion
  - Dendritic Growth
- Activators in flux
- Issues:
  - Is halide free actually more reliable than halide contained?
  - How do you test fluxes for halide content?



# Ionic vs. Covalent Halides

- Ionic halide bonds are typically easily broken; creates free halide to react with moisture to cause corrosion at room temperature
- Covalently bonded halides are much more stable at room temperature; bonds not easily broken
  - At elevated temperatures (such as solder temps) the covalent bonds are broken and halide can react with oxide

Some Ionically Bonded Halides			
Name	Structure	Melting point (°C)	
Dimethylamine hydrochloride	(CH <sub>3</sub> ) <sub>2</sub> NH·HCl	170	
Diethylamine hydrochloride	(C <sub>2</sub> H <sub>5</sub> ) <sub>2</sub> NH·HCl	227	
Diethylamine hydrobromide	(C <sub>2</sub> H <sub>5</sub> ) <sub>2</sub> NH·HBr	218	
Aniline hydrochloride	C <sub>6</sub> H <sub>5</sub> NH <sub>2</sub> ·HCl	196	
Pyridine hydrobromide	C <sub>5</sub> H <sub>5</sub> N·HBr	200d	
Pyridine hydrochloride	C <sub>5</sub> H <sub>5</sub> N·HCl	145	
Ethanolamine hydrochloride	H <sub>2</sub> NCH <sub>2</sub> CH <sub>2</sub> OH·HCl	84	
Diethanolamine hydrochloride	(HOCH <sub>2</sub> CH <sub>2</sub> ) <sub>2</sub> NH·HCl	liquid	
Triethanolamine hydrochloride	(HOCH <sub>2</sub> CH <sub>2</sub> ) <sub>3</sub> N·HCl	177	

# oken and halide can react with oxide Some Covalently Bonded Halides Image: CH2Cl H2C=CH-CH2B: Allyl bromide 3-Bromo-1-propene CH2-CH2 Image: CH2-CH2

# Testing For Halogen Content

- Silver Chromate Paper Test (qualitative)
  - Changes color in the presence of Cl<sup>-</sup> or Br<sup>-</sup>
  - Does not detect Covalently bonded halides
- Titration (quantitative)
  - Solution titrated to endpoint and CI- equivalent is calculated
  - Only detects ionic halides and many chemicals can cause false positive results
- Ion Chromatography (quantitative)
  - Separation of ions and polar chemicals to quantify the amount of halides in a flux
  - Only detects ionic halides and many chemicals can cause false positive results
- Oxygen Bomb + Ion Chromatography
  - Flux is burned at high temperature breaking covalent bonds, volatilizing organics and leaving behind only halide and inorganics in the ash
  - Ion chromatography is run on the ash providing a "true" identification of halide content.



# Indium8.9HF Halogen Summary

- Silver Chromate Paper Test (qualitative)
  - Changes color in the presence of Cl<sup>-</sup> or Br<sup>-</sup>
  - Does not detect Covalently bonded halides
  - Indium8.9HF: PASS
- Ion Chromatography (quantitative)
  - Separation of ions and polar chemicals to quantify the amount of halides in a flux
  - Only detects ionic halides and many chemicals can cause false positive results
  - Indium8.9HF: PASS

#### • Oxygen Bomb + Ion Chromatography

- Flux is burned at high temperature breaking covalent bonds, volatilizing organics and leaving behind only halide and inorganics in the ash
- Ion chromatography is run on the ash providing a "true" identification of halide content.
- Indium8.9HF RAW FLUX: PASS
- Indium8.9HF FLUX RESIDUE: PASS



## Indium8.9HF: 3<sup>rd</sup> Party Oxygen Bomb Testing



TEST REPORT

THE REPORTED TEST RESULTS RELATE ONLY TO THE (TEM(S) TESTED



NSL Lab No: 0821541

Sample ID: 8.9HF(F)

Tests	Results/Units	Methods
Br	<0.001%	Parr Bomb followed by Ion Chromatography
CI	<0.001%	Parr Bomb followed by Ion Chromatopraphy
F	<0.001%	Parr Bomb followed by Ion Chromatopraphy

#### Legend

•(F) Signifies Raw Flux

•(FR) Signifies Flux Residue

NSL Lab No: 0821542

Sample ID: 8.9HF(FR)

Tests	Results/Units	Methods
Br	<0.001%	Parr Bomb followed by ion Chromatooraphy
CI	<0.001%	Parr Bomb followed by Ion Chromatography
F	<0.001%	Parr Bomb followed by Ion Chromatography

Reporting Officer: C Carm D'Agostino , Wet Chem ER 1 Supervisor



## Validation of Printability: Response to Pause

- Powder Sizes
  - Type 3
  - Type 4
- Stencil
  - 5 mil thickness
  - Laser-cut
  - No electropolish
- Aperture Pattern
  - Mask design pads (SMD)
  - Area Ratio
    - A.R. = 0.80 [16 mil circle (C16)]
    - A.R. = 0.60 [12 mil circle (C12)]
    - A.R. = 0.50 [10 mil circle (C10)]
- Motorola RTP
  - ZeroHr; OneHr; TwoHr; FourHr







 $A_{(\text{opening})} = (\pi)(D/2)^2$ 

 $\mathsf{A}_{(\text{walls})} = (\pi)(\mathsf{D})(\mathsf{t})$ 



#### Indium8.9HF: Transfer Efficiency vs. Indium8.9



Test Details: 12mil round CSP deposit analyzed; 5-mil laser cut stencil

Procedure: Print 12 boards; pause 1-hour; print 12 boards

## Indium8.9HF: Transfer Efficiency vs. Indium5.8LS



D : 2576 COMPID : R8H\_SMD

Test Details: 8x50-mil rectangle deposit analyzed; 5-mil laser cut stencil

**Procedure:** Print 6; pause 1-hour; print 6; pause 1-hour; print 6; pause 2-hours; print 6

## Indium8.9HF: No Slumping

#### **Typical Paste**

#### Indium8.9HF



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#### Indium8.9HF: Ultra-Low Via-in-Pad Voiding





•Profiles P1, P5, and P9 targeted

•4-mil microvia on a 12-mil Entek 106A OSP (11 mil aperture)



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Indium8.9HF solder paste exhibits less than 10% voiding across all profiles.



## Indium8.9HF: Wide Profile Window





#### Indium8.9HF: Clear, Pin Testable Residue



#### Indium8.9HF: Wetting & Solder Balling





#### Indium8.9HF: Harsh Profile Graping Improvement







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## Indium8.9HF: Head-in-Pillow (HIP) Reduction

#### **Test Procedure**

- Print paste onto Cu coupon
- Reflow paste on hot plate
- Drop sphere into molten solder at 10 second intervals beginning 10 seconds after going molten





### Indium8.9HF: HIP Reduction







## Discussion



